K

	Application No. Applicant(s)		
Notice of Allowability	09/698,274	YAMAGUCHI ET AL.	
	Examiner	Art Unit	
	Fetsum Abraham	2826	Bu
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) of NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIC of the Office or upon petition by the applicant. See 37 CFR 1.313. 1. This communication is responsive to the RCE and amt forward.	(OR REMAINS) CLOSED in (or other appropriate commur GHTS. This application is su and MPEP 1308.	this application. If not included	
2. The allowed claim(s) is/are <u>6,7,12,31,35,37 and 38.</u>			. :
3. The drawings filed on 30 October 2002 are accepted by the	Examiner.		
4. ☑ Acknowledgment is made of a claim for foreign priority und a) ☑ All b) ☐ Some* c) ☐ None of the:	•	r (f) .	
1. Certified copies of the priority documents have to		•	
2. Certified copies of the priority documents have to	seen received in Application	. No	
3. Copies of the certified copies of the priority doc	ıments have been received i	in this national stage application	n from the
International Bureau (PCT Rule 17.2(a)). * Certified copies not received:			:
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONME THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submitted in INFORMAL PATENT APPLICATION (PTO-152) which gives can be including changes required by the Notice of Draftspersor can be including changes required by the Notice of Draftspersor can be including changes required by the attached Examiner's A Paper No./Mail Date lidentifying Indicia such as the application number (see 37 CFR 1.84 each sheet. Replacement sheet(s) should be labeled as such in the DEPOSIT OF and/or INFORMATION about the deposite attached Examiner's comment regarding REQUIREMENT FOR INFORMATION about the deposite attached Examiner's comment regarding REQUIREMENT FOR INFORMATION and INFORMATION about the deposite attached Examiner's comment regarding REQUIREMENT FOR INFORMATION and INFORMATION about the deposite attached Examiner's comment regarding REQUIREMENT FOR INFORMATION and Information attached Examiner's comment regarding REQUIREMENT FOR INFORMATION and INFORMATION an	ted. Note the attached EXAM reason(s) why the oath or do be submitted. n's Patent Drawing Review (Amendment / Comment or in the comment of the according to 37 CFR 1	MINER'S AMENDMENT or NOTI declaration is deficient. (PTO-948) attached In the Office action of drawings in the front (not the bac	ICE OF
		. •	
Attachment(s)			
Notice of References Cited (PTO-892)		rmal Patent Application (PTO-15	(2)
P. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Sumi	nmary (PTO-413), ail Date	
B. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No./Mail Date	7. Examiner's Arr	mendment/Comment	
Examiner's Comment Regarding Requirement for Deposit		atement of Reasons for Allowand	ce . ·
of Biological Material	9.		
IS Potent and Tandard Com			

Statement of reasons for allowance

Page 2

As a preliminary matter, the advisory action issued on the application on 4/8/04 has been withdrawn.

Claims 6,7,31,37,38 have been allowed. The claimed polycrystalline Thin Film transistor whereby the film contains crystalline grains joined by {111} twin boundaries and is crystallized by introducing group IV elements and their alloys, including the other details of the thin film and the overall structure producing a current path between source and drain regions that is made up of only {110} surface grains is not taught or rendered obvious by the prior arts.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fetsum Abraham whose telephone number is: 571-272-1911. The examiner can normally be reached on 8:00 - 18:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J Flynn can be reached at 571-272-1915.